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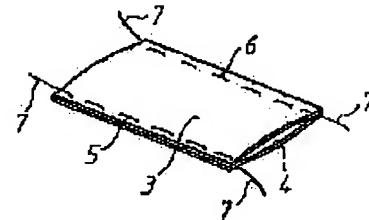
(21)Application number : 09-053763 (71)Applicant : GUNZE LTD  
 (22)Date of filing : 31.01.1997 (72)Inventor : SATO YASUHIRO  
 HASHIMOTO SATOSHI  
 YAMAUCHI KOJI

## (54) SUTURE PROSTHETIC MATERIAL

## (57)Abstract:

PROBLEM TO BE SOLVED: To improve a cutting property by consisting at least part of a suturable material of a foamed film consisting of in vivo decomposition absorptive stock.

SOLUTION: A foamed film 3 consisting of the in vivo decomposition adsorptive stock and a power net fabric 4 are subjected to coarse chain stitching 5, 6 at both selvages and the ends 7, 7 of sewing threads are extended. The constitution obtd. by converging and integrating the front ends of the foamed film 3 and the power net fabric 4 by sewing and providing one of the thread ends with knots and the center of the foamed film body 3 with a notch is equally preferable. Polyglycolic acid, polylactic acid, copolymer of both, etc., are usable for the in vivo decomposition absorptive stock. The power net fabric 4 is preferably used with the fabric which is formed by twill knitting and twill weaving rubber yarn, etc., into the textile weave and has stretchability in longitudinal and transverses; for example, the fabric formed by knitting the yarn formed by covering polyurethane yarn with nylon yarn to a warp knit weave. The resistance value to cutting is lower and the cutting property is improved by such constitution.



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